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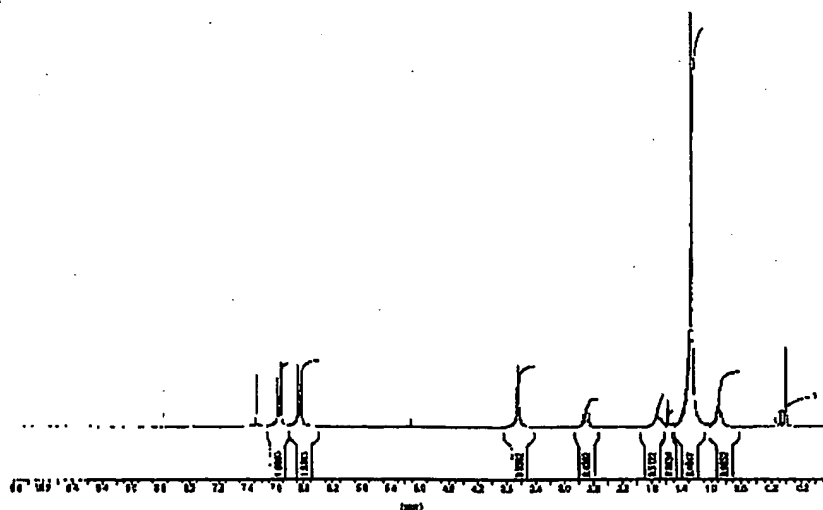
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(54) Title: **DIAMINE COMPOUND CONTAINING TRIAZINE GROUP, POLYAMIC ACID SYNTHESIZED FROM THE DIAMINE COMPOUND AND LC ALIGNMENT FILM PREPARED FROM THE POLYAMIC ACID**



(57) Abstract: Diamine compound containing specific triazine group, polyamic acid obtained by reacting the diamine compound and tetracarboxylic dianhydride, and liquid crystal alignment film obtained by coating and imidizing the polyamic acid. The liquid crystal alignment film has good heat-resistance, high transparency in visible light region and improved voltage holding ratio. Also, pretilt angle is easily controlled over broad range.

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